

REVIEW

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Strategies for the synthesis of complex oxides for application as light-responsive electrodes in photoelectrochemical cells – a review

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Complex oxides have emerged as potential next-generation components for photoelectrodes in reactors for solar energy conversion, due to their improved sunlight harvesting and enhanced stability in comparison to well-known semiconductors based on binary oxides. However, the experimental performances achieved with these emergent materials are still far from the theoretical values. The properties of these complex oxides largely depend on structure, particle-size, morphology and other tuneable characteristics that can be controlled by the synthesis methodology. The aim of this review is to discuss recent progress in synthesizing multinary complex oxides, presenting some common and also less conventional synthesis approaches, which are organized here into “dry” or “wet” methods. Then, we hope to contribute to the development of n and p-type semiconductors for photoelectrochemical generation of fuels like H₂ from water splitting and C-based products from CO₂ reduction or biomass valorisation, as well as, other reactions in the field of sustainable energy.

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1. Introduction

Efficient solar energy conversion and storage are contemporary challenges in the field of clean and renewable energy sources. Among the investigated approaches, the photoelectrochemical

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Dr. Nadia Guerra Macedo received her PhD in Chemistry from the University of São Paulo in 2015. After that, she worked as a post-doc researcher at the Federal University of São Carlos, from 2016 to 2018, in a Materials Sciences Group, and from 2019 to 2023 as a post-doc in the laboratory of Prof. Claudia Longo, at the University of Campinas. She works in interdisciplinary areas like materials chemistry, physical chemistry and nanotechnology.



Jéssica Costa Alvim

also a visiting student at Imperial College London under supervision of Prof. James Durrant (2023–2024). Her thesis investigates complex oxides for photoelectrochemical solar fuels production and the development of photo-responsive gas diffusion electrodes for the CO₂ reduction reaction.

Jéssica Costa Alvim received her BSc degree in chemistry from the Federal University of Santa Maria (UFSM, Brazil) in 2020. During her undergraduate course she developed research projects in biochemistry, analytical chemistry, and materials. Currently, she is PhD student at the University of Campinas (UNICAMP, Brazil) under the supervision of Prof. Dr Claudia Longo in the Group of Photoelectrochemistry and Energy Conversion. She is



(PEC) production of fuels is a green strategy that combines the use of light-responsive electrodes in electrochemical cells (or reactors) with electrical energy and solar radiation. The use of a light source coupled to the electrochemical approach can lead to more efficient carbon-neutral fuel production due to the electron/hole charge-carrier separation that can occur on solar-irradiated semiconductor electrodes. Using, for instance, a p-type semiconductor electrode, the electrons can migrate to the electrode surface which reduces the necessity of electrical power to promote reduction reactions. On the other hand, n-type semiconductors can be used as photoanodes to promote oxidation reactions.^{1,2}

PEC devices can be employed to produce chemical feedstocks of great interest, like green H₂ from water splitting,³ or high added value carbon based products, such as alcohols and hydrocarbons, from the reduction of CO₂ gas.⁴ However, for the

assembly of PEC devices with scalable application it is essential to develop suitable and efficient photoelectroactive materials to be used as photoanodes (or photocathodes) where light-driven redox reactions of interest will occur.

The performance of a photoelectrode in a PEC device includes its ability for light harvesting and the efficiencies for charge carriers formation, separation, and transport, as well as its photostability in the electrolyte solution. These properties are highly influenced by the synthesis method, which determines the intrinsic structural characteristics of the photoactive material, and some properties, such as the level of crystallinity, morphology, grain size and presence (and type) of defects.^{5,6} Semiconducting oxides are preferred photoelectrodes for PEC solar fuels production, given their general inexpensive processing costs and, in many cases, thermodynamic stability in aqueous medium.^{7,8}



Leonardo Carvalho Soares

Leonardo Carvalho Soares received his Masters degree from the Federal University of Maranhão (UFMA – Brazil) in 2019. Currently, he is pursuing a PhD degree at the State University of Campinas (UNICAMP – Brazil). Recently, he worked as a visiting researcher at the University of Manchester (UoM – United Kingdom, 2022–2023). His work investigates the development of photoanodes based on BiVO₄ photoanodes for the oxygen evolution reaction and glycerol oxidation, with application in photo-reactors for CO₂ reduction.



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Vanderlei Silva Lima obtained his Masters degree in chemistry, in 2018 from the University of São Paulo (USP, Brazil). There, he carried out research at the Laboratory of Electrocatalysis and Environmental Electrochemistry with a research project in biomass conversion (glycerol) in fuel cells. He is currently doing his PhD at the State University of Campinas (UNICAMP, Brazil), under the supervision of Prof. Dr Claudia Longo in the photoelectrochemistry and Energy Conversion Group with a research project on the photoelectrochemical reduction of CO₂.



The most investigated photoanodes consist of binary oxides, such as TiO_2 and $\alpha\text{-Fe}_2\text{O}_3$. However, these broadly investigated compounds also exhibit limitations. For instance, TiO_2 presents excellent stability; however, due to the relatively large bandgap energy ($E_g \sim 3.0\text{--}3.2$ eV), only a small portion of the electromagnetic spectrum is absorbed, limiting the solar energy harvesting and the maximum photocurrent that can be achieved.⁸ The sunlight harvesting could be more efficient with $\alpha\text{-Fe}_2\text{O}_3$ photoelectrodes ($E_g \sim 2.0\text{--}2.2$ eV) but the short carrier lifetime (with high electron-hole recombination rates) and the poor transport properties prevent the maximum photocurrent theoretical value of 12 mA cm^{-2} from being obtained.^{9,10} Moreover, there are oxides that present severe instability in irradiated aqueous solution, such as ZnO and Cu_2O , requiring the development of protective layers and/or cocatalysts.^{11,12}

Complex multinary oxides formed by different cations enable band engineering and synergic effects, through electronic interactions of individual elements resulting in semiconductors with improved properties.¹³ Moreover, there are almost innumerable possible combinations, ~ 8000 for ternary (two metallic cations) and $700\,000$ quaternary compounds (three),^{14,15} and only a few have been studied so far.

However, there are some challenges involving multinary oxides, such as screening of the ideal components, which is now more efficiently carried out using computational methods.¹⁵ Another bottleneck is related to the synthesis procedures, since the presence of multiple cations in the reaction can result in sub-stoichiometries and phases segregations. Traditionally, synthesis methods of inorganic materials classified as “dry” or “wet” have been used. However, interesting results have also been obtained using less conventional synthesis techniques.

The aim of this review is to discuss the main synthesis strategies used to obtain complex oxides for application as

photoelectrodes in PEC cells, dedicating more attention to unconventional methods. First, we briefly present the fundamentals of semiconductor electrodes and PEC processes; then, the main methods used to synthesize inorganic semiconductor photoelectrodes are presented; and finally, literature examples of some of the most promising complex oxides for application as photoanodes and photocathodes in PEC reactors are discussed.

2. Fundamentals: semiconductors, photoelectrodes and photoelectrochemical cells

2.1 Energy diagrams of the semiconductor electrode/electrolyte interface

The interaction of semiconductors with electromagnetic radiation, the key aspect for solar energy conversion, can be discussed considering energy diagrams describing the band gap energy (E_g) that separates the valence and the conduction band (VB, CB) edges. The absorption of photons with energy equal or higher than E_g causes the excitation of electrons from VB to CB, leaving positively charged holes (h^+) in the VB. Then, the photogenerated electron-hole pair must be separated and collected for applications related with solar energy conversion.^{2,8}

When a semiconductor electrode is immersed into an electrolyte solution, charge rearrangement will occur at the photoelectrode interface to minimize the difference between semiconductor Fermi energy (E_F) and the electrolyte electrochemical potential (E_{EC}). As a result, a differential distribution of charges is formed between the semiconductor's bulk and surface, generating a space-charge layer, which causes band bending and enhances the separation of the photogenerated carriers at the semiconductor/electrolyte interface.^{4,8}

As illustrated in Fig. 1, this difference in concentration of charge carriers will shift the E_F of a semiconductor. However, E_{EC} remains almost unchanged because the number of electroactive species in the electrolyte is significantly higher compared to the number of mobile charge-carriers in the semiconductor. For an n-type semiconductor E_F is located slightly below the CB and then, to attain electrochemical equilibrium, electrons flow from the electrode to the solution, lowering the semiconductor E_F . Thus, for an n-type semiconductor upward band bending occurs in the space-charge layer generating an electric field in the semiconductor/electrolyte interface, which is crucial for the separation of photogenerated charge carriers. This way, when an n-type semiconductor is irradiated, holes can migrate to the material interface and promote oxidation reactions.

Conversely, for p-type semiconductors E_F is located slightly above the VB; therefore, downwards band bending will take place as a result of electron transfer at the space charge layer to achieve the electrochemical equilibrium. The electric field generated from downwards band bending is the key to a p-type semiconductor for operating as a photocathode: under irradiation, electrons will flow towards the semiconductor surface, being available to perform reduction reactions. The band



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at Universities of Texas-Arlington and California-Santa Cruz (2011, Capes-Fullbright). The publications reflected interests in solar energy conversion, comprising semiconductors synthesis, characterization, and application in solar cells, for the removal of contaminants of emerging concern from water and for producing “solar fuels” from photoelectrochemical CO_2 reduction.





Fig. 1 Energy diagrams for n-type and p-type semiconductor electrodes immersed in an electrolyte with electrochemical potential (E_{EC}) at non-equilibrium (a) and (c) and in equilibrium (b) and (d) with the Fermi level of the semiconductor (E_F).

bending can also be modulated by application of an external electrical potential to the electrode. Additionally, polarization can enhance the separation of the photogenerated carriers at the semiconductor/electrolyte interface and improve the current flow.⁴

A typical PEC cell is constituted by at least one photo-responsive semiconductor electrode, that uses the photogenerated carriers to promote redox reactions. The application of a semiconducting material as a photoelectrode in a PEC cell depends on the relative positions of the CB and VB edges to promote reactions of interest, such as H_2 production from water, CO_2 reduction, and others. Fig. 2 shows examples of some semiconductor oxides and their CB and VB relative positions.

2.2 Evaluating the efficiency of photoelectrodes in PEC cells

Understanding of photoelectrode abilities for solar energy conversion requires several studies. The measurements of

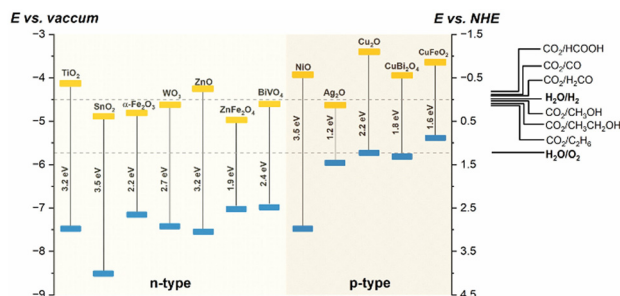


Fig. 2 Relative CB and VB edge positions (yellow and blue rectangles, respectively) for some semiconductor oxides in aqueous solution (pH 0), and the potentials of reactions of interest versus vacuum (left) and NHE (right).^{16–19}

incident photo-to-current conversion efficiency (IPCE) consist of the ratio of incident photons that are converted in electrical current. The IPCE maximum can usually be associated with the E_g and is also affected by the redox reaction kinetics and charge generation, separation, and transport processes. The IPCE is estimated under monochromatic irradiation, as represented by (eqn (1)).

$$IPCE(\lambda) = \frac{j_{ph}(\text{mA cm}^{-2}) \times 1239.8 (\text{V nm})}{P_{mono}(\text{mW cm}^{-2}) \times \lambda (\text{nm})} \quad (1)$$

J_{ph} is the photocurrent density, P_{mono} is the power intensity of monochromatic light at a discrete wavelength (λ), and 1239 V nm is the product of Planck's constant and the speed of light divided by the electron charge ($h \times c/e$).

Here it is important to mention that the “maximum theoretical photocurrent” is a value calculated assuming that every photon with energy $\geq E_g$ is absorbed and generates an exciton that is collected without recombination (thus, disconnected with particular reactions).¹⁰

The PEC cell efficiency, which depends on the photoelectrode activity, can be evaluated considering the current flow and the production rate of gaseous or liquid molecules with time. The faradaic efficiency (FE) for each product can be estimated using eqn (2) considering the amount of produced substance (η), the amount of electrons involved in the redox reaction (n), and the total charge passed through the external circuit (Q), where F is the Faraday's constant (96485 C mol^{-1}).²

$$FE (\%) = \frac{n(\text{electrons}) \times \eta(\text{product}) \times F}{Q} \times 100 \quad (2)$$

When different products are obtained, the FE indicates the system selectivity for every product and allows us to discuss possible side reactions (including photocorrosion). For instance, the hydrogen evolution reaction (HER) is an important side reaction that decreases FE of solar fuel production from the photoelectrochemical reduction of CO_2 .

Finally, the solar-to-fuel efficiency (STF) can be calculated from eqn (3), considering the rate of fuel production (r_{fuel} , in mmol s^{-1}), the standard Gibbs free energy of product formation (ΔG^0 , in kJ mol^{-1}), the power density of incident irradiation (P , in mW cm^{-2}), and the geometric area of the photoelectrode (A , in cm^2).²⁰

$$STF = \frac{r_{fuel} (\text{mmol s}^{-1}) \cdot \Delta G^0 (\text{kJ mol}^{-1})}{P (\text{mW cm}^{-2}) \cdot A (\text{cm}^2)} \quad (3)$$

2.3 Considerations on the stability of photoelectrodes in PEC cells

The successful application of a photoelectrode in PEC cells also depends on the semiconductor stability under the practical conditions of PEC cell operation. The electrolyte pH and composition, applied potential, and irradiation processes may affect the photoelectrode long-term stability. Bismuth vanadate ($BiVO_4$), for instance, an n-type semiconductor, is largely used as a photoanode for the oxygen evolution reaction (OER) only



under mild pH conditions (pH 5–9), since it is soluble in strongly alkaline media (pH > 11). In contrast, the n-type semiconductor α -Fe₂O₃ is suitable for alkaline conditions.⁸

The irradiation process can also affect the photoelectrode stability because the photogenerated e^-/h^+ pair may cause self-photocorrosion in some semiconductors. For instance, cuprous oxide (Cu₂O), a p-type semiconductor, presents photocorrosion upon illumination in aqueous medium, which results from simultaneous self-oxidation to copper oxide (CuO) and self-reduction forming metallic copper (Cu). Toe *et al.* investigated the Cu₂O photocorrosion pathway using e^- and h^+ scavengers and concluded that self-photooxidation ($Cu^+ + h^+ \rightarrow Cu^{2+}$) is the main cause of Cu₂O degradation.²¹

Usually, the long-term stability of a photoelectrode can be evaluated by monitoring the generated photocurrent within time, and by observing the rate of product formation. The semiconductor surface morphology and crystal structure should also be monitored before and after utilization in PEC cells using X-ray diffraction (XRD), X-ray photoelectron spectroscopy (XPS), scanning electron microscopy (SEM), and/or transmission electron microscopy (TEM). These studies contribute to the understanding of materials instability and can help to develop strategies to enhance the semiconductor electrode long-term stability.²²

3. Synthesis aspects

The overall PEC performance of semiconductor electrodes depends on both intrinsic and tuneable characteristics of materials, such as defects and surface aspects.²³ In particular, the materials nanostructuring can provide an increase in the surface area; an improvement in the electron-hole diffusion processes; mitigation of electron-hole recombination, *etc.*²⁴ These features, and consequently the final properties of the electrode, are synthesis-dependent. The choice of an appropriate synthesis method relies on good previous knowledge of the different techniques available and on the influence on structure, phase stability, and characteristics of each material.

The synthesis methods can be classified in two large categories: (i) “dry methods” (solid phase), for those processed without solvents; and (ii) “wet methods”, for those with a major component in the liquid phase.

Solid-phase reactions usually require extreme conditions to overcome thermodynamic barriers and compensate the low diffusion transport of reactants. Wet synthesis routes (or solution based), instead, generally take place under milder conditions, like lower temperatures, since transport in the liquid phase is favoured.²⁵ The main appeal of solution based methods is the simultaneous generation of several stable small nuclei, resulting in (mono) dispersed nanoparticles (NPs). However, these NPs can suffer Ostwald ripening, which implies the smaller particles precipitate onto larger ones, increasing the final particle size.²⁶

The choice of synthesis method will depend, mainly, on the final application and on the technical apparatus available.

In this work, we will comment on the most feasible and common techniques for semiconductors production, as well as some less practiced, but possible alternatives, here named “unconventional dry and wet methods”.

3.1 Traditional “dry” methods

Among the most traditional methods to produce ceramics, one finds solid-state reaction (SSR) and milling, which can be used independently or in combination.

3.1.1 SSR. The SSR consists of heating at high temperatures, for several hours (or days), a mixture of solid precursors, like carbonates, oxalates, hydroxides, nitrates, and oxides. Although simple, the main SSR limitations include the low diffusion of components in the final product, heterogeneous particle size distribution and large crystalline domains.²⁷ These characteristics can be deleterious for PEC applications, providing, for example, poor electrical contact with the conductive substrate. However, small modifications in the synthesis protocols, like the use of small granulometry polycrystalline precursors (up to 10 μ m) or the use of compounds that decompose into oxides before or during the reaction can lead to finely divided powders.

3.1.2 Milling. Milling is a common mechanical process to pulverize and homogenize solids by successive fractures of particles, and is an effective way to decrease particle size. There are various types of mills available for a variety of applications and a great example for synthesizing semiconductors are ball mills (Fig. 3), which consist of an apparatus to put together some hard spheres and precursor powders in a closed special chamber.

The grinding process is driven by high energy collisions among the spheres and the reactants, resulting in size reduction of the micro crystallites into highly homogeneous nanometric structures, with or without chemical reactions.²⁸ There are a wide variety of ball mills (cup, friction, shaker, vibration and planetary), constructed with dense materials such as tungsten carbide, steel, or zirconia.²⁹

Beyond ball mills, there are other types of mill apparatus. One of them is the stirring mill, which is preferable for faster and highly energetic reactions, and when only small amounts of precursor (in the order of a few grams) are available. In other ways, dry milling is an appropriate strategy to induce chemical reactions in the synthesis route. The appropriate choice of the pulverization process even brings some interesting properties to ground material.

In general, high-energy grinding can be considered an environmentally friendly, reliable, reproducible, and easy-to-use process with low costs. This is due to the possibility to use easily accessible raw materials on its powder form. However, the milling process has its own limitations that can affect the final properties of the desired product, such as agglomeration of powders and cross-contamination from mills.

Complex oxides can also be obtained using these methods. As an example, in a recent work, Wang *et al.*³⁰ reportedly obtained vanadium-zircon (V–ZrSiO₄) from a first mix and grinding of precursors followed by calcination of a precursor





Fig. 3 Schematic cross-sectional representation of the milling process for synthesizing smaller-sized powder products from reactant mixtures.

mixture at high temperature, in this case, 500 to 900 °C for some hours.

3.2 Traditional “wet” methods

The traditional solution-based methods used to produce complex oxides include sol-gel, hydrothermal and electrodeposition. As these are well-known methods for synthesizing materials, we will just briefly comment on the general aspects of each one.

3.2.1 Co-precipitation. Co-precipitation, a traditional procedure for obtaining inorganic solid materials, involves the addition of a precipitating agent to a solution containing dissolved salts. Co-precipitation includes simultaneous processes, like nucleation, growth, agglomeration, and others, where the nucleation step is the key point to be controlled to form small particles. Trivially, if crystallites are formed too quickly, they tend to aggregate into larger particles, which are thermodynamically favoured in the growth step. Thus, the final size will be largely affected by a secondary process, such as particle aggregation and the Ostwald ripening phenomenon.²⁶ The size, morphology and structures of precipitated particles can be modulated with some reaction parameters, like precursors and solvent compositions, concentrations, precipitant, capping agent, temperature, pH, time, *etc.*

Semiconductor oxides can be directly obtained *via* co-precipitation, when the precipitate is itself the desired oxide, and thermal treatment is only for crystallinity improvement, or indirectly, when precipitated as a precursor that is further thermally converted into the final oxide. Saib and collaborators precipitated AgCoO₂ nanocrystallites (~20 nm) from Co³⁺/Ag⁺ aqueous solution, using NaOH as the precipitant agent, at relatively low temperature (80 °C).³¹ They observed that the product is a p-type semiconductor with possible application as a photocathode for the HER. In another work, Priya *et al.* firstly precipitated a sample of mixed hydroxides from a Bi³⁺/W⁶⁺/Fe³⁺

aqueous solution employing NH₄OH as the precipitating agent, with posterior solvothermal treatment (160 °C/24 h) and annealing at 600 °C, resulting in BiFeWO₆ nanoparticles.³²

To sum up, co-precipitation is a simple route, with several advantages such as no necessity of expensive equipment and reagents, good control of precipitated properties, and compatibility to large-scale industrial production. The limitations include the absence of precise temperature control, time-consuming protocols for some syntheses, yield limited by precursor solubility and the recurrent necessity of additional steps for purification and post-treatments.³³

3.2.2 Sol-gel. A sol-gel process involves the hydrolysis of a monomer precursor into a colloidal solution (sol), and subsequent formation of an integrated network (gel) of either discrete particles or networked polymers. The as-obtained gel is then subjected to a drying process, and the resulting product is readily converted to xerogel or aerogel, according to the drying method.³⁴ A scheme of the process is shown in Fig. 4.

One key advantage is the presence of an organic precursor matrix, that ensures the mixture of different metals on an atomic scale.³⁵ However, in the synthesis of ternary or quaternary oxides, the different hydrolysis rates of precursors can lead to phase separation during the condensation step, which can prevent the achievement of multicomponent oxides. Then, small molecules such as citric acid and acetylacetone can be employed to form stable aqueous metal complexes, decreasing the hydrolysis rate of reactive precursors.^{35,36}

The sol-gel process also requires thermal post-treatments to remove organic residues and hydroxyl groups on the surface of the desired crystalline material, causing some difficulties related to non-uniform heating and undesired reactions with ceramic crucibles.³⁷ However, this synthesis technique presents several advantages including low cost, low temperature (soft chemistry), simple experimental set up, and allowing a high control of parameters (pH, concentration of reactants, nature of solvent, type of additives, aging of solution, and others).^{36,38}

Furthermore, major drawbacks found in the conventional sol-gel method were overcome with non-hydrolytic sol-gel chemistry. In this process, the condensation step is carried



Fig. 4 Schematic representation of the sol-gel procedure for the preparation of a compound from precursor solutions.



out in non-aqueous media with an oxygen-donor other than water (e.g. ethers, carboxylates and alcohols). Non-hydrolytic conditions allow more controllable kinetics compared to traditional hydrolysis reactions, resulting in better control of the crystallization phase, in particular of pure multi-metal oxides.³⁹

Sheikh *et al.* synthesized a composite of BiFeO₃ and La₂NiMnO₆ to be used as the photoanode for water splitting with improved PEC performance ($\sim 14.07 \text{ mA cm}^{-2}$ – more than 50% increase in comparison to the bare BiFeO₃ in the same work) and a maximum photon-to-current conversion efficiency of $\sim 9.61\%$.⁴⁰ In another work, Xie *et al.* prepared a W:BiVO₄–FeCoW heterojunction with sol–gel followed by post-annealing. The photoanode exhibits a photocurrent which is enhanced to ~ 3.8 times that of a W:BiVO₄ photoanode at 1.23 V vs. the reversible hydrogen electrode (RHE).⁴¹

3.2.3 Hydrothermal/solvothermal. The hydrothermal (HT) method was created with geological inspiration, which is the action of water under high temperature and pressure in the formation of rocks. HT processing consists of a chemical reaction in the presence of an aqueous solvent above the room temperature and pressure greater than 1 atm in a closed system. When the solvent is something other than water, the method can be defined as solvothermal (ST).⁴²

HT and ST are among the main methods for fabricating nanostructured and advanced materials, providing an excellent environment for crystal growth with control over size and morphology, with the formation of monodispersed NPs. Additionally, HT processing brings several other advantages, such as lower sintering temperatures and reaction times, when compared to traditional ceramics synthesis methods; the obtainment of products with higher purity and good homogeneity; narrow particle size distributions; crystal symmetry and even the possible formation of metastable compounds.⁴² HT/ST are also possible alternatives to produce materials that cannot be synthesized using traditional ceramic methods with controllable size and morphology, due to the evaporation of reactants, or metastable structures with special valence states.^{42,43}

Again, surface aspects, like morphology and particle size, can be tailored by varying the different reaction parameters, such as time, temperature, pressure, pH, concentration of reactants, capping agent, *etc.*⁴⁴ Recently, a review by Wu *et al.* discussed ternary Bi-based oxides like γ -Bi₂MoO₆, Bi₂MoO₆, and Bi₂WO₆ obtained using HT and ST methods.⁴⁵ In another work, a dumbbell morphology of CaBi₂O₄, with submicrometric sizes of 300 nm diameter and 500 nm length, was obtained. When electrodes of this semiconductor were applied for PEC water splitting, a photocurrent of 0.83 mA cm^{-2} at 1.23 V vs. RHE was generated without hole scavenger, and 1.19 mA cm^{-2} vs. RHE using Na₂SO₃ as the hole scavenger.⁴⁶

Due to these advantages, there are a significant number of studies reporting the synthesis of complex oxides and their composites using hydrothermal methods. The main drawbacks rely on safety concerns (the internal pressure in the stainless-steel vessel must be controlled) and the process scale-up (adaption of the equipment for larger volumes operation).

3.2.4 Electrodeposition. Electrodeposition allows the deposition of films on conductive substrates from a solution containing electroactive species (also including ionic liquids and fused salts) using electrochemical processes. The process is performed inside an electrochemical cell filled with a liquid solution of precursor ions, two or three electrodes and a device capable of controlling the potential or the electrical current in the electrochemical cell. Other elements like a thermometer, heat source, gas inlet/outlet and stirrer can also be used.⁴⁷

Fig. 5 displays a scheme of different electrodeposition procedures. The electrodeposition can be carried out either under potentiostatic control, by setting a constant voltage between the working electrode (WE) and reference electrode (RE), while the current flows between the WE and auxiliary electrode (AE) (Fig. 5(a)). The applied voltages are higher than equilibrium potential (overpotential) to overcome reaction kinetics limits. The key advantages of the potentiostatic mode are film purity and the adjustable atomic ratio of the electrodeposited elements, which have great impact on the semiconductor properties (n or p-type).⁴⁸

The electrodeposition can also be achieved under galvanostatic control with the electrical current between the WE and CE (counter-electrode) kept constant. Then, only two electrodes are required (Fig. 5(b)) and the cell potential is not equal to the WE potential. The potential fluctuation can be attributed to changes in WE conductivity, due to semiconductor film growth, and to the decreasing of the ionic activity of precursor in the electrolyte during the electrodeposition process. Thus, side reactions can take place to maintain the current value, which can impact the purity and properties of the deposited film. In good practices, either the cell or WE potentials should be monitored, to avoid damage in the electrodes or solvent decomposition.⁴⁹

There is another approach, the anodization mode, that uses the conductive substrate itself as the metal ion source. This method has been applied as a reliable way, e.g., to produce vertically aligned nanostructures and nanoporous films. The synthesis is processed in two electrode-cells (Fig. 5(c)), where the WE is the anode (so the term anodization is used). The film formation is generally modelled as a process of field-assisted



Fig. 5 Electrochemical cells setup for electrodeposition through: (a) potentiostatic, (b) galvanostatic, and (c) anodization procedures. WE – working electrode; RE – reference electrode; AE – auxiliary electrode; and CE – counter-electrode.



oxidation, and the nanostructures grow due to the migration of ions from the substrate into the interface due to an electric field, in an electrochemical dissolution reaction, followed by precipitation. These oxidations can be achieved under either current or potential controlled modes. Potentiostatic regimes are the most used, due to the easiness of morphology control. The syntheses of metal nanotubes often use potentials in the range of 5 V to 30 V in water or even more in organic solvents.⁵⁰ The main drawback of anodization is the fact that not all metals and alloys can be used, only a few, that can form passivation layers (valve metals) (e.g. Ti, Al, Nb).⁵¹

Despite the simplicity, the solvent, pH, metal precursor and electrolytes play important roles in electrodeposited material properties. For instance, water is the most used solvent, however it has a limited potential range of 0 V to +1.23 V (*vs.* SHE), which are related to HER and OER, respectively. Thus, if the potential of interest is close or over these limits, the faradaic efficiency may decrease. Precursor solubility is also an important point to consider. Commonly used non-aqueous solvents are ethylene glycol, DMSO and acetonitrile. Although most electrodepositions are performed under room conditions, temperature is another factor that can be optimized, since some reaction kinetics are slower than desired. Although a temperature rise implies faster deposition, it must be carefully controlled, otherwise the film is formed too quickly, with poor uniformity and adhesion on the substrate.⁵²

Although many semiconductor oxides are directly synthesized with high quality and crystallinity, it is not always possible to co-electrodeposit metals to produce multinary film oxides. In some cases, the compound is synthesized as a precursor (*i.e.* hydroxides), which further undergoes thermal treatment to improve its crystallinity, or to chemically produce a more complex compound. An example is iron oxyhydroxide (FeOOH), which has been synthesized using different electrochemical routes,^{53,54} and further converted to α -hematite (α -Fe₂O₃) *via* annealing. These combined techniques can also be used for the synthesis of more complex multimetal oxides. For instance, Labchir *et al.* demonstrate the formation of a cobalt ferrite (CoFe₂O₄) film by mixing the cation sources of Co²⁺ and Fe²⁺ precursors in the electrolyte, followed by heating (24 h at 500 °C).⁵⁵

In summary, the electrodeposition method is a simple, versatile, and relatively low-cost method, generally performed under mild conditions, such as room temperature and atmospheric pressure. Although poor practices can lead to non-uniform film thickness and low adhesion, effective methodologies allow the fine control of deposited film composition, thickness and morphology, resulting in films with excellent adhesion and uniform electrical contact to the substrate.

So far, we have reviewed the most used “dry” and “wet” methods for the preparation of complex oxides. A direct comparison among these methods is not straightforward. Furthermore, the synthesis choice must consider the target material and the available resources. Regarding some “dry” methods, like SSR, the oxides of interest are generally obtained with good crystallinity, but also with large and irregular grains.



Fig. 6 Comparison of the main aspects involved in traditional “dry” (solid-state reaction and milling) and “wet” (co-precipitation, sol–gel, solvothermal and electrodeposition) synthesis protocols.

Then, milling post treatments are required to improve the adhesion and the electrical contact to the electrode substrate surface (like fluorine-doped tin oxide – FTO). Conversely, wet methods, like HT, generally produce well-defined morphologies and smaller sizes, but with lower crystallinity, requiring posterior annealing steps. Finally, the methods that can directly generate the oxide phase on the substrate, like electrodeposition, or even HT, when the FTO is placed with the precursors inside the autoclave, tend to form oxide films with adequate electrical contact with the substrate, a required characteristic for electrodes. Fig. 6 summarizes the comparison between general “dry” and “wet” techniques. In the next section we discuss some less investigated, but possible techniques for the preparation of PEC materials.

3.3 Unconventional “dry methods”

3.3.1 Vapor deposition. Vapor deposition methods, such as physical or chemical vapor deposition (PVD, CVD respectively), are more sophisticated synthesis routes since they involve the transfer of material at an atomic level to a specific target (substrate) and can be used to produce thin films with a high purity level and growth control, as will be outlined in.

3.3.1.1 Pulsed laser deposition (PLD): a type of PVD. PVD uses high power energy sources to melt, evaporate and ionize the surface of a target material under ultra-high vacuum conditions. Initially, the material is ablated by a high energy source, which produces a plume of the target’s constituents. Then, the “vaporized” atoms are transported to the substrate to be coated. Generally, this is carried out under ultra-high vacuum conditions.⁵⁶

PLD, a particular type of PVD, uses a laser with a high-power density and narrow frequency bandwidth as a source for vaporizing the target material. This technique was first used by Smith and Turner, in 1965, for the preparation of semiconductors and dielectric thin films.⁵⁷ Later, in 1987, the technique was established with the work of Dijkamp and coworkers at high temperature, which generally occurs in straight paths.⁵⁸





Fig. 7 Scheme of pulsed laser deposition equipment.

The plume of vaporized material reacts with the appropriate gas during the transport stage (which may be oxygen, nitrogen, or methane) and deposits on the substrate. This technique is particularly used for thin film preparation: the material ejected from the target is collected on a previously selected substrate on which it condenses, and the thin film grows,⁵⁹ as represented in Fig. 7.

When the objective is the production of electrodes, a conductive substrate is used; for example, to obtain thin films of metallic oxides, nitrides or carbides, the target should consist of metals or even ceramic materials with that chemical composition. The films produced using the PVD technique have interesting characteristics, such as a high level of hardness and resistance to wear, friction, and oxidation. A review from 2019 focused on synthesis for water splitting materials and reported PVD techniques to obtain single crystalline thin films with improved properties.⁶⁰

The PLD technique has many advantages in the growth of thin films over other techniques. Among them are the easiness to form compounds with controllable stoichiometry, the high deposition rate, and the control over the film thickness. The fact that the laser is used as an external energy source results in a process where the surface is extremely clean and free of contaminants. However, there are many variables that can affect film properties, such as laser fluency, background gas pressure, and substrate temperature.

PLD can be employed for the growth of multilayers of different chemical compositions with an epitaxial relationship between domains. This kind of approach is quite satisfactory to produce photoelectrodes containing heterojunctions, where the contact between the crystalline structures of the different domains must be closely interconnected. In the next section, we discuss a case of successful synthesis of a ternary oxide, CuBi_2O_4 on a template *via* this epitaxial growth.

Although the advantages are quite attractive,⁶¹ and the technique could be successfully applied for the direct production of complex multication oxides such as the challenging structure of $\text{Ba}_2\text{Co}_2\text{Fe}_{12}\text{O}_{22}$,⁶² the technique has some challenges to overcome, which limits the use of PLD mainly in

academic and small-scale studies, (typically $\sim 1.0 \text{ cm}^2$) preventing its industrial widespread use.⁶³

3.3.1.2 Chemical vapor deposition (CVD) and atomic layer deposition (ALD). Chemical vapor deposition (CVD), defined as the deposition of a solid on a heated surface from a chemical reaction in the vapor phase, has been a well investigated technique since the mid-1960s, progressing very rapidly in recent decades.⁶⁴ Unlike PLD techniques, CVD is a part of many industrial manufacturing processes used to produce semiconductors and many other material types.⁶⁵

The CVD process can involve many chemical reactions and events, that can basically be described in the following sequence: ① reactant gases enter the reactor by forced flow and diffuse through the boundary layer; ② gas adsorption occurs at the substrate surface; ③ a deposition reaction takes place; ④ desorption of reaction gaseous by-products occurs and ⑤ by-products diffuse away from the surface, through the boundary layer. These events are summarized in Fig. 8.^{66,67}

CVD is a relatively simple and economically competitive technique that allows the coating of surfaces of any shape and various sizes, also permitting changes in deposition rates, chemical composition and co-deposition of elements or compounds. Different from PVD processes, the CVD equipment does not normally require ultra-high vacuum and is not restricted to a line-of-sight deposition. Generally, CVD is a single operation and an integral part of a manufacturing process, particularly in microelectronics. Most manufacturers have their own CVD facilities, which makes it difficult to implement a unified experimental setup.⁶⁶

The microstructure varies depending on the material to be deposited. In general, ceramics obtained by CVD, such as SiO_2 , Al_2O_3 , Si_3N_4 , and most dielectric materials tend to be amorphous or, at least, have very small grain microstructure. On the other hand, deposited metals tend to be more crystalline. The crystal size of the deposits is also a function of deposition conditions, especially temperature. Moreover, through the pressure control, it is possible to control the thickness of the boundary layer and, consequently, the degree of diffusion.⁶⁸

In 2006, Grätzel and co-workers synthesized thin films of silicon-doped $\alpha\text{-Fe}_2\text{O}_3$ deposited by atmospheric-pressure CVD



Fig. 8 Sequence of events during the chemical vapor deposition process.



from $\text{Fe}(\text{CO})_5$ and tetraethoxysilane on SnO_2 -coated glass at 415°C . As a result, they obtained dendritic nanostructures with excellent performance as a photoanode for water splitting in 1 M NaOH, that exhibited 42% of IPCE at 370 nm and 2.2 mA cm^{-2} in AM 1.5G sunlight of 1000 W m^{-2} at $1.23\text{ V}_{\text{RHE}}$.⁶⁹

The synthesis of complex oxides by CVD is possible, as there are adequate precursors for each metal present in the final oxide. The reactants must then be highly volatile molecules, which is a problem for some electropositive ions that tend to form ionic compounds. However, some alternatives are possible, as reported by Bekermann *et al.* to obtain the superconductor $\text{YBa}_2\text{Cu}_3\text{O}_7$: volatile molecules of the metal precursors were substituted by their complexes, such as yttrium with 2,2,6,6-tetramethyl-3,5-heptadione, allowing the use of CVD.⁷⁰

Despite several advantages, the high operating temperatures of the CVD technique (above 600°C) are among the main drawbacks since many substrates are not thermally stable at these temperatures. Improvements of deposition conditions and precursor properties, such as Metallo-Organic CVD and plasma-enhanced CVD, partially compensates this problem, but it makes the process more expensive. Another challenge is the need for chemical precursors with high vapor pressure, which are often dangerous and sometimes extremely toxic. The by-products of CVD reactions can also be toxic and corrosive and must be neutralized, which can be a costly operation.⁶⁰

In conclusion, the CVD technique allows the deposition of thin films on conductive substrates and, although not yet widely used for photoelectrodes synthesis, has great potential for this purpose.

In contrast, atomic layer deposition (ALD), a very close process to CVD, has recently attracted much attention for PEC applications, due to its unique nature for precise control over film thickness and growth of complex nanostructures. ALD is based on a gas–solid reaction where the adsorbed molecules in each reaction cycle is one monolayer, resulting in a layer-by-layer growth mechanism.⁷¹ The deposited film can act, then, as a protective layer, or by increasing the absorption range of the solar spectrum, also by decreasing the recombination rate of photogenerated charge carriers.

A good example, reported by Paracchino and coworkers is the correlation of the ALD deposition temperature of $\text{Al}:\text{ZnO}$ and TiO_2 protective layers and their band energy positions, a critical factor to enhance carrier separation.^{72,73} ALD is an ideal technique for the deposition of protective layers, uniformly sealing irregular surface topologies of nanostructured substrates such as Si nanowires, InP nanopillars, and cubic Cu_2O with structures.

3.4 Unconventional “wet methods”

3.4.1 Microwave-assisted methods. One general characteristic of solution-based methods is the use of conventional heating with ovens or heating plates. Although the temperatures of such methods are generally lower than those used for solventless methods, this type of heating can be relatively time and energy consuming, also exhibiting many disadvantages, such as high thermal gradient effects, slow reaction

kinetics, *etc.* These drawbacks can severely influence the crystallization conditions, resulting in poor nucleation and wide size distribution.⁴⁴

In this sense, microwave equipment can be an excellent alternative to conventional heating. Microwaves, which are electromagnetic energy with a frequency in the range of 300 MHz to 300 GHz, interact with materials *via* two mechanisms: dipole interaction and ionic conduction. Microwave-assisted techniques show efficient heat transfer and can be a fast, clean, low-cost, and environmentally friendly approach to produce high yield advanced materials.⁷⁴

HT and ST are the most common microwave assisted methods, with the substitution of a traditional oven by a microwave source. A simple microwave oven can be adapted and employed in several types of “wet” methods to improve the synthesis efficiency with much shorter periods of time. The microwave-assisted HT was used to produce a nanocomposite of $\text{In}_2\text{O}_3/\text{ZnO}$ and resulted in flower morphologies with petal diameters of 30 nm that exhibited PEC degradation of methylene-blue dye under visible-light.⁷⁵

Microwave heating is also used in solventless reactions. Houl *et al.* prepared porous hematite photoanodes with worm-like networks using hydrothermal deposition and microwave-assisted rapid annealing of a $\beta\text{-FeOOH}$ nanocube film on the FTO.⁷⁶ According to the authors, since FeOOH , Fe_2O_3 and graphite are good microwave absorbers, the rapid conversion of FeOOH into Fe_2O_3 could be achieved through rapid microwave-assisted annealing. Furthermore, the water elimination derived from the constitutional OH groups in FeOOH would facilitate the formation of uniform pores in Fe_2O_3 , resulting in a hematite electrode that exhibited an enhanced performance for PEC water oxidation, with an IPCE of 51% at 340 nm at 1.23 V vs. RHE .

While microwave heating can be very time and energy saving, the technique requires adaptation of the equipment (especially when used in combination with the hydrothermal method) which can bring safety issues, and due to the rapid annealing, the final products can present defected or non-well-defined morphologies.

3.4.2 Solution combustion synthesis. Solution combustion synthesis (SCS) allows functional materials to be obtained in many fields of application. Recently, Carlos *et al.* and Siddique *et al.* reviewed the use of SCS to produce metal oxides and photocatalysts, respectively.^{77,78} However, it is still a much less known and rather unusual method for obtaining photoelectroactive materials for PEC applications.

The origins of SCS go back to the materials chemistry in mid-1980s literature. Though the invention of this process was recently claimed by some authors regarding a patent, the credits must be given to Ravindranathan and Patil who first observed the formation of metal oxides from the thermal decomposition of multiple metal organic complexes.⁷⁹

In a broader sense, combustion can be defined as the reaction between a fuel and an oxidizer, which reacts rapidly with each other in a highly exothermic process, in most cases forming gaseous species as products. In SCS, metal oxides



particles are obtained due to some particularities, such as: (i) the fuel is an organic complexing agent, which binds to metal cations and forms metal–ligand adducts; (ii) the oxidizer is a chemical agent added to the reaction mixture; (iii) both oxidizer and (metal-bound) fuel are not directly mixed; instead, both species are solubilized in a solvent, water being most commonly used.

After metal salt, fuel and oxidizer are dispersed in solvent, the reaction mixture is placed in a cup or crucible, which is then heated in a furnace or hot plate until the activation energy for the combustion reaction is achieved. The reaction occurrence is well-described as a multistep process. Given that the reactants are dispersed in a solvent, the first step needed is solvent evaporation, resulting in a solid (or gel) mixture of metal–fuel complexes and oxidizer molecules. This solid/gel mixture is further heated until the ignition temperature is reached, which will then start the reaction between fuel and oxidizer. The following step is a cascade of self-supported reactions which provides the entire energy needed for the SCS completion, as the temperature inside the reaction vessel can reach up to 1800 °C. A violent release of fumes (H_2O , CO_2 , N_2 and others) is observed at this point of the process, which will then proceed until depletion of reactants. The final product is usually a foamy, porous, and finely dispersed solid together with a multitude of solid contaminants/ashes which originate from incomplete combustion. A schematic diagram summarizing this process is shown in Fig. 9.⁸⁰ Table 1 summarizes combinations of metal salts, fuels and oxidizers used in a few representative works recently describing SCS of complex metal oxides.

As can be seen from Fig. 9 and the previous discussion, classical reaction parameters such as temperature and pressure are not exactly tuneable in SCS procedures. Meanwhile, after the onset temperature is reached, all the energy input for the oxide formation arises from the combustion reaction, at which the reaction temperature may increase to much higher values than the onset temperature, as shown for instance in the formation of iron oxide nanoparticles by the SCS reaction.⁸¹ The intense temperature peak is mainly associated with the formation of hypergolic mixtures of gases from the initial reaction between the fuel and oxidizer.⁸² In this sense, the most

important reaction parameters to be tuned in SCS procedures are the nature of fuel and oxidizer and their ratio.

The reaction mechanism, thermodynamics, and kinetics, which are beyond the scope of this work, have been thoroughly studied, and the reader is referred to some review papers.^{83,84} Specifically for PEC applications, the SCS products show both positive and negative aspects that must be considered. While particle size and shape control stand as highly tuneable features in SCS, ash contaminants and a lack of control in oxidation states are drawbacks for some materials, in addition to reaction hazards. These aspects will be discussed in the following section and as should be noted, the main aspect underlying these features is the fuel/oxidizer composition and ratio. As mentioned before, organic fuels used in SCS procedures act as complexing agents to produce metal–ligand complexes. These interactions are well-known to have a profound influence on geometry/morphology during nanoparticle growth by sol–gel or hydrothermal synthesis and as expected, the same is observed for SCS.

The use of additives can also influence the morphological aspects of SCS products. Cobalt/iron oxide synthesized by SCS showed a dramatic increase in BET surface area when KCl is added to the precursor mixture.⁹³ Depending on the KCl/fuel ratio, the obtained surface area was as high as $115 \text{ m}^2 \text{ g}^{-1}$, a 10-fold increase when compared to the $11 \text{ m}^2 \text{ g}^{-1}$ observed in the absence of KCl. Glycine was used as a fuel for all the experiments, so the mechanism proposed by the authors involves the formation of a KCl crust around each metal nucleation seed after solvent evaporation, which would in turn avoid aggregation while the system is at high temperatures. Though this alone was provided as a satisfactory explanation, no mention to binding energies or nucleation *vs.* growth dynamics was provided, which could give additional insights into the observed differences.

As the reader may have noticed, up to this point all the transition metal-based SCS-derived samples presented herein are constituted by cations at their most stable oxidation state, for instance Cu^{2+} , Fe^{3+} , Nb^{5+} , and Bi^{3+} . This should be expected, given that high temperatures and oxidant species are present in the reaction environment. Metals at intermediate oxidation states such as Cu^+ and Fe^{2+} are rarely observed in samples obtained directly from SCS without any post-treatment. Nonetheless, some authors have shown it is possible to obtain lower oxidation states and even metallic particles, depending on the fuel/oxidizer ratio. By providing a fuel-rich mixture, the reaction environment after self-ignition of the precursor mixture can become a high-temperature mixture of reductant gases, such as NH_3 and H_2 , among others.⁸³

This can in turn be used to promote the formation of heterostructures which are interesting for general catalysis, such as mixtures of copper oxides with Cu cations at different oxidation states,⁹⁴ nickel oxide decorated with metallic nickel domains,⁹⁵ magnetite-containing iron oxides,⁹⁶ and $\text{Ce}^{3+}/\text{Ce}^{4+}$ CeO_2 nanostructures to name a few.⁹⁷ However, it must be noted that precise control of multiple phases/oxidation states is not straightforward, and synthesis of pure-phase low valence



Fig. 9 Schematic representation of SCS synthesis of copper vanadates. Adapted with permission from ref. 80 Copyright 2019 American Chemical Society.



Table 1 Different combinations of fuels and metal salts for the SCS of photoactive complex oxides

Metal salts/oxidizer	Fuels	Product	Ref.
Co(NO ₃) ₂ , Al(NO ₃) ₃	Glycine, PVA, urea	CoAl ₂ O ₄	85
Mn(NO ₃) ₂ , Zn(NO ₃) ₂ , Fe(NO ₃) ₃	Citric acid	(Co, Mn, Zn)Fe ₂ O ₄	86
Fe(NO ₃) ₃ , Mg(NO ₃) ₂	Citric acid	MgFe ₂ O ₄	87
M(NO ₃) _x (M = Co, Fe, Mn, Ni, Al, Cr, Sr)	Glycine	LaMO ₃	88
Cr(NO ₃) ₃ , Cu(NO ₃) ₂	Glycine	CuCrO ₂	89
Cu(NO ₃) ₂ , Zn(NO ₃) ₂ , C ₄ H ₄ NNbO ₉	Urea	CuNb ₂ O ₆ , ZnNb ₂ O ₆	90
Bi(NO ₃) ₃ , NH ₄ VO ₃ , HNO ₃	Citric acid, PEG 6000	BiVO ₄	91
Cu(NO ₃) ₂ , NH ₄ VO ₃	DL-Malic acid	α-CuV ₂ O ₆	92

complex oxides might not be achievable by SCS, depending on the compound family being studied. This can be seen even for monometallic oxides such as, for instance, copper oxides. As shown by Hossain *et al.*, pure phase Cu⁺ oxide cannot be obtained over a broad range of fuel/oxidizer ratios (Fig. 10).⁹⁸ Higher selective for Cu₂O arises on slightly fuel-rich mixtures, but a small increase in fuel amount leads to the formation of metallic copper.

Iron/aluminum spinel oxide, FeAl₂O₄, is an interesting case on lower oxidation state. The low-valency characteristic of iron cations in this structure is attributed to different reasons, such as a reductive environment and combustion of ionic liquids, with no further details on the mechanism or thermodynamics.⁹⁹ Generally, iron oxides obtained by SCS usually provide structures with Fe³⁺ solely, such as LaFeO₃⁸⁸ and MgFe₂O₄.⁸⁷

SCS is a chemical reaction which occurs under extreme conditions, with significant evolution of heated gases. The amount of evolved gas can be estimated from the stoichiometric ratios of metal precursors and fuels. For instance, CuCrO₂ is a representative example of the remarkable extension of gas evolution during SCS. Varga *et al.*⁸⁹ propose the following chemical reaction using metal nitrates as precursors and glycine as fuel:

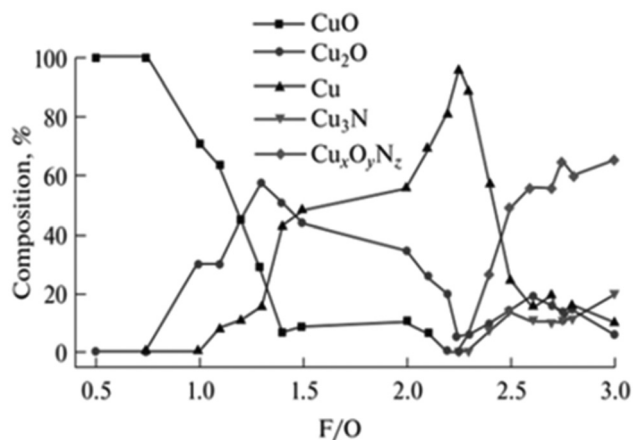


Fig. 10 Product composition obtained from SCS synthesis of copper oxides with different fuel/oxidizer ratios. Reprinted (adapted) with permission from ref. 94 Copyright 2018 Allerton Press, Inc.

This indicates that, for each mole of CuCrO₂ formed during SCS, 17 moles of high temperature gases (CO₂, N₂ and steam) will theoretically quickly evolve from the reaction vessel. As the authors indicate that the reaction temperature reaches values above 900 °C, it could result in 1.6 m³ of hot gases for each mole of CuCrO₂, in a rough approximation using the Clapeyron equation. This estimative, though somewhat inaccurate, indicates a significant risk posed by gas evolution during SCS. To avoid incidents, some authors report the use of more sophisticated reactors for SCS rather than a lab beaker or crucible. Indium/gallium oxides were obtained by SCS using a mixture of metal nitrates and hydrazine,⁹⁹ from which gaseous hypergolic mixtures can potentially evolve. In this case, a sophisticated reactor with gas flow, pressure/temperature control and a protective insulation was used, and the reader is referred to this work for a detailed design figure. Iron oxide was also obtained by SCS using a reactor with gas outlet and protective elements.⁸¹ Nonetheless, common beakers and crucibles are still frequently used for SCS, as can be seen in some recent papers.^{83,96,100,101} These references show representative photos of the evolution and outcome of SCS procedures and the reader is referred to those, to be aware of what infrastructure might be necessary to perform SCS at the lab.

Incomplete combustion is often observed in SCS systems, and the resulting byproducts can be different types of N,C-containing ashes. This means that one should pay special attention to washing procedures after SCS, to assure that no contaminants are present when the obtained oxides are applied, especially for PEC applications. The presence of carbonaceous contaminants can be misleading when one is performing CO₂ reduction experiments, given that part of the detected products may originate from the conversion of carbon-containing molecules instead of CO₂. It must also be noted that nitrogen incorporation into oxide structures has been observed, for instance in the case of copper oxides.⁹⁴

To sum up, these non-conventional procedures also present advantages and disadvantages. However, it is possible to list some common features. Usually, methods that produce oxide films directly grown on the substrate generally result in electrodes with superior properties. However, as in the case of PVD methods, expensive equipment that requires ultra-high vacuum conditions are needed. Moreover, high temperatures can damage the substrate and precursors can volatilize, in the case of CVD. In contrast, solution combustion is operationally simpler, but is still not adequate for direct film preparation.



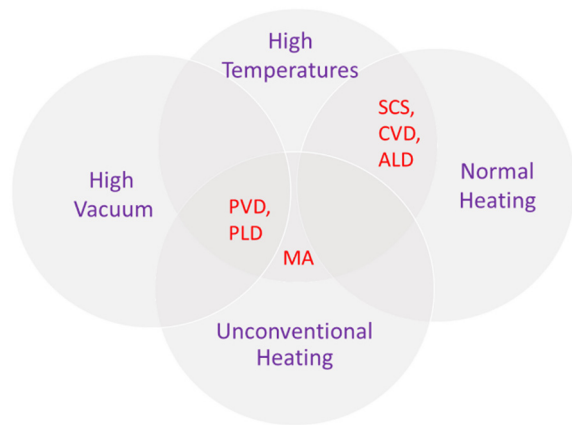


Fig. 11 Scheme of intercessional features for unconventional dry (physical vapor deposition, pulsed laser deposition, chemical vapor deposition, atomic layer deposition) and wet (microwave-assisted and solution combustion synthesis) methods.

Additionally, microwave assistance can solve long time exposure, but involves safety concerns with the adaptation of equipment. Thus, the choice of synthesis approach should consider syntheses conditions, apparatus, and final product. Fig. 11 is a scheme showing the intercessional features of each of the discussed less investigated methods for PEC applications.

4. Complex metal oxides – synthesis and challenges

In this section we discuss the current synthetic routes to obtain some of the promising complex oxides for application as photoelectrodes.

4.1 BiVO₄ and the ferrites for application as photoanodes for oxidation reactions

Bismuth vanadate, in the monoclinic crystallographic phase, is probably the most investigated complex oxide for PEC applications. The m-BiVO₄ stands out as an n-type semiconductor with absorption in the blue-ultraviolet range of light (2.4–2.5 eV), suitable band edge position for water oxidation ($E_{VB} = +2.4 V_{RHE}$), long free photogenerated charge carrier lifetime ($\tau \cong 40$ ns, $\lambda = 450$ nm), few inherent recombination sites, and highly defect tolerant. However, intrinsic drawbacks such as short carrier diffusion lengths and relatively low carrier mobility ($\sim 4 \times 10^{-2} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ at 1 sun), prevent the achievement of its theoretical photocurrent (7.5 mA cm^{-2} , AM 1.5G).¹⁰²

The performance of BiVO₄ photoanodes can be enhanced using different strategies, such as surface morphology engineering, doping, heterojunctions, cocatalysts addition, or a combination of them. However, in this review, we will focus on the synthesis of pristine BiVO₄, since extensive reviews on the methods to enhance the BiVO₄ properties can be found in recent literature.^{103–105}

Bismuth vanadate photoanodes can be obtained with good reproducibility by electrodeposition. The main protocol, which

consists of the co-electrodeposition of vanadium and bismuth ions from the deposition bath, was first reported by Seabold and Choi.¹⁰⁶ They correlated the electrodeposition time with film thickness and photocurrent density. Recently, Mohamed *et al.* also demonstrated that film thickness, light harvesting properties and electrochemical performances can be controlled by the electrodeposition time.¹⁰⁷

Another electrodeposition-based methodology was developed by McDonald and Choi in which BiOI films are first electrodeposited.^{108,109} The further conversion into BiVO₄ is achieved by the impregnation of this precursor with a vanadium source (VO(acac)₂, NH₃VO₃) dispersed in an aprotic solvent, and posterior thermal treatment at temperatures up to 450 °C (eqn (5)). To date, this is still the most used route to build up highly active photoanodes. An interesting feature of photoanodes synthesized from BiOI precursor is high porosity, an inherited characteristic from void space between the 2D structure of BiOI plates. In an extensive work, Tolod and co-workers performed a deep investigation into how the synthesis factors, such as electrodeposition time, bath composition and calcination temperature, affect the BiVO₄ film performance for the OER.¹¹⁰ They found that the photocurrent densities, and other parameters like onset potentials, charge transfer resistance and density of donors were dictated by the following characteristics: crystallite size, film thickness and porosity.¹⁰⁸



Although not mentioned yet, successive ionic layer adsorption and reaction (SILAR) is a layer-by-layer type methodology to grow films. In general lines, SILAR is a multistep dip-coating impregnation, where it is possible to easily modulate the film thickness. As demonstrated by Yassin, Sin and Jennings,¹¹¹ and then by Seong and co-workers,¹¹² the direct deposition of BiVO₄ is achieved by reacting ammonium vanadate bismuth nitrate solutions on a conducting substrate. The authors observed that the as-synthesized films possess a porous texture, composed by fused particles with a size lower than 150 nm, and adjustable thickness in the range of 2 to 5 μm. These two steps are considered as one SILAR cycle. In this process, the film thickness will be proportional to the total number of deposition cycles. The advantages of this technique when compared with electrodeposition are the absence of an electrical power source, and the use of simpler precursor solutions. Fig. 12 is a scheme showing the main BiOI precursor methods discussed here. In the insets it is possible to see the SEM morphology change observed due to the transformation of BiOI to BiVO₄ because of the step in Fig. 12(c), which is common after treatment with both electrodeposition and SILAR methods.

Deposition of the complex oxide film directly on a conductive substrate is very appreciable in terms of adherence and electrical contact between the semiconductors phase and the substrate, important characteristics for photoelectrodes. However, some articles also report the production of BiVO₄ particles *via* traditional wet-synthesis methods, and its posterior deposition on appropriate substrates, like FTO. Samsudin



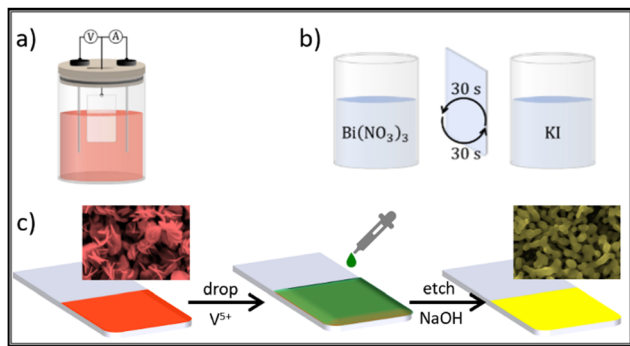


Fig. 12 BiVO₄ synthesis via BiOI template through: (a) electrodeposition; (b) SILAR; and (c) drop cast of V precursor for thermal conversion BiOI → BiVO₄ common to both approaches.

et al. modulated the BiVO₄ morphology by playing with a wide range of pHs and temperatures using HT synthesis and then the obtained particles were deposited on FTO *via* a doctor blade.¹¹³ Among the 13 variations, the sample synthesized at pH = 1.96 and 120 °C presented micro flower morphology with 1–2 μm leaf-like structures. Under an applied potential of 0.7 V *vs.* RHE, the resulting photoelectrode rendered the highest photocurrent density, 5.66 mA cm⁻², producing 9.52 mmol L⁻¹ of hydrogen in the counter electrode, within 7 h. This study shows an interesting correlation of PEC performance and semiconductor morphology (influenced by synthesis procedure).

Sol-gel was also performed for the preparation of BiVO₄ photoelectrodes. Hilliard *et al.* produced semi-transparent BiVO₄ thin films by dipping FTO on bismuth nitrate(III) and vanadyl acetylacetonate dispersed on a mixture of acetic acid and acetylacetone.¹¹⁴ The electrodes consisted of 10-layer BiVO₄ films, 75 nm thick, exhibiting a photocurrent of 2.1 mA cm⁻² (1.23 V *vs.* RHE) with 85% of faradaic efficiency for the OER in neutral pH. Shim *et al.* introduced polyethylene glycol (PEG) as a strategy to produce nanoporous BiVO₄ photoanodes doped with molybdenum and observed that both PEG molecular weight and annealing temperature affected the final particle size, which varied from 50–150 nm. The photoanodes could

generated 4.5 mA cm⁻² of photocurrent (1.23 V *vs.* RHE) for 10 hours.¹¹⁵

Considering “dry-methods”, synthesis protocols of metal oxides involving a combination of milling and annealing are often found in the literature. Dömen and co-workers reported highly crystalline BiVO₄ structures with an average size of 300–500 nm using a combination of a SSR, ball milling and then, annealing (the thermal treatment was used to improve crystallinity). The resulting crystalline BiVO₄ photoanode generated a stable photocurrent of 2.5 mA cm⁻² at +1.2 V (*vs.* RHE) in 1.0 M borate buffer (pH 9) for 2 h in PEC OER.¹¹⁶

Kölbach and co-workers produced a BiVO₄ film on FTO substrate (25 mm × 25 mm) by alternating the ablation of Bi₂O₃ and V₂O₅ precursor pellets. This approach overcomes the inhomogeneity generated by the non-stoichiometric distribution of Bi:V from the conventional ablation of BiVO₄ pellets and also makes the annealing step unnecessary. The resulting FTO|BiVO₄ electrodes (90 nm thick) generate 2.6 mA cm⁻² (at +1.23 V *vs.* RHE) for sulphide oxidation under 100 mW (A.M 1.5).¹¹⁷

Since BiVO₄ is a ternary oxide largely investigated for PEC applications, we summarized in Table 2 the PEC properties of this material, according to different synthesis approaches discussed previously.

Complex oxides based on iron, a low-cost and earth abundant element, have also been investigated for application as photoanodes in PEC reactors. Ferrites are ternary oxides with spinel (or inverse spinel) type crystalline structures with the general formula MFe₂O₄ (M = Cu, Mn, Mg, Zn, Ni, Co and other metals). Generally, ferrites are synthesized from a combination of some binary metal oxides with α-Fe₂O₃ (hematite), from which they inherit most properties, like good chemical stability and low bandgap energy values.¹¹⁸

However, ferrites usually present an indirect bandgap that decreases the sunlight harvesting.¹¹⁹ Moreover, compared with hematite, ferrites also present poor charge transport properties but have superior photostability; ferrites photoelectrodes can promote the OER (or HER) for a longer time without the need for protective layers.^{120,121}

ZnFe₂O₄ was first introduced as a photoanode in 1985 by De Haart and collaborators.¹²² The material was synthesized using

Table 2 Photoelectrochemical performance of BiVO₄ photoelectrodes prepared with different syntheses methods^a

Synthesis approach and precursors	Polymorph/particle size	Photo-electrode and application	<i>J</i> and applied <i>E</i>	Ref.
SCS Bi(NO ₃) ₃ ·6H ₂ O, NH ₄ VO ₃ , citric acid, PEG 6000, urea.	Monoclinic 1–10 μm	ITO BiVO ₄ for dye degradation	0.09 mA cm ⁻² +1.40 V <i>vs.</i> Ag/AgCl	91
Electrodeposition Bi(NO ₃) ₃ ·5H ₂ O, KI, VO(acac) ₂ , DMSO, <i>p</i> -benzoquinone and HNO ₃	Monoclinic 100–500 nm	FTO BiVO ₄ /FeOOH/NiOOH for OER	3.2 mA cm ⁻² +0.6 V <i>vs.</i> RHE	109
HT Bi(NO ₃) ₃ ·5H ₂ O, NH ₄ VO ₃ and HNO ₃	Monoclinic and tetragonal 1–2 μm	FTO BiVO ₄ for OER	5.66 mA cm ⁻² +0.70 V <i>vs.</i> Ag/AgCl	113
Sol-gel Bi(NO ₃) ₃ ·5H ₂ O, VO(acac) ₂ , methanol, MoO ₂ (acac) ₂ , PEG 200, acetic acid	Monoclinic ≈ 278 nm	FTO Mo:BiVO ₄ /NiFeOOH for OER	4.5 mA cm ⁻² +1.23 V <i>vs.</i> RHE	115
PLD Bi ₂ O ₃ , V ₂ O ₅ , isopropanol	90 nm monoclinic	FTO BiVO ₄ for OER/sulphide	2.4 mA cm ⁻² +1.23 V <i>vs.</i> RHE	117

^a The syntheses and precursors are related to the BiVO₄ phase.



a solid-state reaction at 700 °C of pellet-shaped solids in an inert atmosphere. The photocurrent density measured under 300 nm light irradiation for this n-type semiconductor was 0.01 mA cm⁻² at 1.23 V_{RHE} in NaOH electrolyte (pH 14). Since then, different synthesis strategies have been applied to obtain ZFO, such as CVD, electrodeposition, precipitation, and HT assisted by microwaves.^{123–125}

Kim *et al.*¹²¹ synthesized nanostructured pristine ZnFe₂O₄, and this ferrite with Ti⁴⁺ and Sn⁴⁺ n dopants, using a two step procedure. In the first step, FeOOH nanostructures with rod-like morphology were prepared on a conductive substrate using the HT method. Subsequently, the FTO/FeOOH was calcined at high temperature with a large amount of Zn solution and after, the excess of ZnO layer on the surface was removed by alkaline solution, resulting in pure ZnFe₂O₄. The strategy of synthesis of nanorods directly on the FTO substrate is extremely efficient in the formation of ordered anisotropic structures, characteristics that favour the transfer of charge, being easily implemented for the preparation of ferrites.¹²⁰ Different treatments were then performed to improve the performance as photoanodes for the OER. Pristine ZnFe₂O₄ electrodes treated by hybrid microwave annealing presented a photocurrent density 2.8 higher than the electrodes treated at low temperature using conventional thermal annealing. Since metal oxides, like ZnFe₂O₄, are poor microwave absorbers, graphite was added to enhance the microwave absorption due to alterations of dielectric properties, promoting self-heating.¹²⁵ The highest performance was obtained for the 2% Ti-doped ZnFe₂O₄ annealed at 800 °C, with a photocurrent density of 0.312 mA cm⁻² at 1.23 vs. RHE; this represents a ~18 times increment from that of pristine ZnFe₂O₄ annealed at 550 °C. Despite the increments, these values are lower than those recently reported for pristine hematite photoanodes (*ca.* 0.75 mA cm⁻²) or Hf-doped hematite (2.07 mA cm⁻²) at 1.23 V vs. RHE.¹²⁶

Hematite can act as a good model for the ZnFe₂O₄ performance improvements, since both have a low photon absorption coefficient and poor charge separation at the surface and in the bulk. To improve the charge transfer kinetics at the interface and to decrease the overpotential for the OER, deposition of metal oxides and metal complexes of Ir, Co, Fe, and Ni, OER catalysts, has been used as a complementary strategy. For example, amorphous FeNiOx, that can be easily anchored at the ZnFe₂O₄ surface using different techniques, can improve the photoelectrode efficiency and stability for the OER.¹²⁷

Other spinel metal ferrites MFe₂O₄, (M = Cu, Mg, Ca) have also attracted attention as suitable photoanodes for PEC water oxidation because of small bandgaps (1.9–2.4 eV), stability in alkaline electrolyte, and low cost, due to the availability of these earth-abundant elements.¹²⁸ A variety of modification strategies have been applied to improve their efficiency, including nanostructuring, doping, substrate engineering, post-treatment with a reductive gas and advanced annealing, which are found to be effective for other oxide-based photoelectrodes in general.^{9,129}

To sum up, the use of ferrites as photoelectrodes for water splitting can be limited by unfavourable optical, electronic, and

charge transport properties. However, different strategy synthesis can circumvent these limitations, and can help to transform ferrites into an important class of materials for PEC applications.

4.2 Photocathodes – the Cu-based oxides

Although there are well-established materials for application as photoanodes in PEC reactors, such as m-BiVO₄ and α-Fe₂O₃, no benchmark photocathode had been reported at the time this review was organized. Photocathodes require p-type semiconductors, which are rarer and more difficult to obtain from low-cost and abundant materials than n-type semiconductors. Some Ag and Cu based compounds can act as p-type semiconductors;^{12,130} moreover Cu-based materials have been attracting more interest, particularly for the CO₂ reduction reaction (CO₂RR), since copper compounds generally favour the conversion of CO₂ into C₂ and C₃ products, such as ethanol and propanol.¹³¹

However, Cu oxides, especially as binary materials, tend to suffer from rapid photocorrosion in irradiated aqueous solution, which is attributed to the Cu₂O/Cu reduction potential value, placed within the semiconductor band gap. Nevertheless, some Cu-based ternary oxide photocathodes demonstrated superior photostability compared to the binary oxides.¹³² The introduction of a more stable transition metal, such as Fe or Bi, would direct photogenerated electrons toward these stable metals, instead of Cu 3d orbitals.¹³³

In this sense, nowadays CuFeO₂, and CuBi₂O₄ are the most promising ternary oxides for application as photocathodes, in terms of photocurrent generation and photoelectrochemical stability.

CuFeO₂. The CuFeO₂ mineral delafossite nominates the class of ABO₂ oxides with a structure constituted by mono (A) and trivalent (B) cations, piled on monoatomic triangular layers, with the space group *R*3̄*m*, as shown in Fig. 13(a). The B atoms rely on the centre of distorted oxygen octahedral, forming characteristic BO₂ sandwich layers, interlinked by linear O–A–O bonds, in a two-fold coordination.¹³⁴

CuFeO₂ is an interesting candidate for PEC applications, particularly H₂ generation, with appropriate absorption and band alignment with water reduction potential, as depicted in Fig. 2. The valence band is mainly composed of Cu 3d and O 2p orbitals, while the VB and CB edges are constituted by Cu and Fe 3d states, with a band gap energy in the order of ~1.5 eV (but with variable values found in the literature).¹³⁵ Additionally, CuFeO₂ consisted of earth-abundant elements, with favourable stability (mainly in alkaline electrolytes) and relatively high conductivity, due to the high covalent character of the Cu–O bond when compared to typical metal–O bonds in other oxides.¹³⁶

Although promising, the synthesis of pure CuFeO₂ remains a challenge. The Cu–Fe–O system is highly influenced by temperature and Cu/Fe ratio and the CuFeO₂ synthesis in high temperatures usually generates CuO, Fe₂O₃ and CuFeO₄ as side products.¹³⁷ In Fig. 13(b), we reproduce an experimental phase diagram built from thermogravimetric (TGA) and differential





Fig. 13 (a) Delafossite ABO_2 crystal structure. Atoms by colours: A (orange), B, (green), and oxygen (red). Reproduced unchanged from ref. 134 according to <https://creativecommons.org/licenses/by/4.0/> ©2017 Informa UK Limited, trading as Taylor & Francis Group. (b) Experimental phase diagram of the Cu–Fe–O system in air, with experimental points with an accuracy of $\pm 2^\circ\text{C}$ for the transition temperatures. D = delafossite; L = eutectic $\text{CuFeO}_2 + \text{Cu}_2\text{O}$; spinel + $\text{CuFe}_2\text{O}_4 + \text{Fe}_3\text{O}_4$. Reprinted (adapted) with permission from ref. 138 Copyright 2019 American Chemical Society.

analysis (DTA) data in air, complemented by *in situ* XRD, and field-emission-gun electron probe microanalysis (EPMA) studies by Shorne-Pinto and co-workers.¹³⁸ The delafossite temperature formation relies on the interval ranging from 1022 to 1070 $^\circ\text{C}$, where decomposition starts, with the possible formation of non-stoichiometric forms that could compromise the PEC performance.

Pure phase CuFeO_2 crystals are usually obtained under temperatures above 1000 $^\circ\text{C}$, an inert atmosphere, or high vacuum. However, the synthesis of hexagonal crystallographic phase ($P6_3/mmc$), referred to as 2H- CuFeO_2 can occur *via* low-temperature solution-based methods. Jin and Chumanov used high basic conditions at temperature $<100^\circ\text{C}$ and obtained 2H- CuFeO_2 nanoplates, 100 nm thick, with E_g of 1.33 eV for photovoltaic applications.¹³⁹ HT can also be used for non-pure CuFeO_2 synthesis, including for direct deposition on FTO, as described by Tu and Chang (in most conditions with Cu_2O impurities) for application in the degradation of dyes.¹⁴⁰

Several studies report the combination of “wet” methods followed by post-annealing treatments in temperatures lower than 800 $^\circ\text{C}$. In 2015, Sivula and co-workers obtained nanoporous CuFeO_2 films with ~ 300 nm of thickness using a sol-gel method, further deposited on FTO using spin-coating, with subsequent heat and depositions, and a final treatment under 700 $^\circ\text{C}$ by 12 h.¹⁴¹ The effects of deposition of Pt particles, aluminum-doped ZnO and TiO_2 overlayers (15 nm/100 nm) by atomic layer deposition, were also evaluated. These electrodes exhibited a photocurrent density of 0.4 mA cm^{-2} for water reduction at 0 V vs. RHE in 0.5 M Na_2SO_4 (pH 6.1). When the delafossite layers were intercalated with oxygen using a post annealing process at 300 $^\circ\text{C}$, photocurrents of 1.51 mA cm^{-2} at 0.35 V vs. RHE were reached for the oxygen reduction reaction. Furthermore, bare CuFeO_2 electrodes were highly stable at potentials where photocurrent is observed, without degradation for

at least 40 h under operating conditions in oxygen-saturated electrolyte.

Other combinations of methods are also observed. Recently, Luo *et al.* previously synthesized bulk CuFeO_2 by SSR combined with pressure-less synthesis, followed by a heteroepitaxial growth of 16 nm thick CuFeO_2 films on sapphire substrates using PLD.¹⁴²

In 2016, Jang and co-workers¹⁴³ used a synthesis method based on direct spin coating deposition of copper and iron nitrate precursors on a FTO substrate on a hot plate (450 $^\circ\text{C}/1$ H). After this step, the electrodes were annealed for 10 h under Ar flow, at 500, 600 or 700 $^\circ\text{C}$, to transform amorphous copper iron oxide into a crystalline delafossite structure. Furthermore, the films were submitted to different post treatments (conventional annealing at 300 $^\circ\text{C}/1$ h, or microwave heating for 1 to 15 min). The PEC experiments were then conducted for the HER at 0.4 V vs. RHE in aqueous 1 mol L^{-1} NaOH. While the non-heated electrode exhibited a photocurrent of only -0.3 mA cm^{-2} , conventional thermal annealing doubled the photocurrent to -0.62 mA cm^{-2} . In its turn, the microwave heating enhanced the photocurrent about 4 times, $\sim -1.3 \text{ mA cm}^{-2}$ at 0.4 V vs. RHE. They claim that thermal treatment works by intercalating extra oxygen into the CuFeO_2 lattice, which increases the charge carrier density, improving charge transport properties. They also conclude that when the annealing is made *via* microwave, the oxygen intercalation occurs more uniformly over the whole solid, being more effective.

However, as observed by Lumley *et al.* the microwave treatment can cause significant changes in the delafossite structure, since Cu^{1+} ions can be easily oxidized to Cu^{2+} ; then, CuO can be produced when CuFeO_2 is heated in the air, influencing the PEC electrode performance.⁷ Thus, any air treatment of Cu^{1+} ternary oxides should be carefully investigated to assure that the enhancement in photocurrent is only due to changes in the bulk lattice of the original compound and not to the formation of some CuO.

Furthermore, Mg^{2+} can substitute Fe^{3+} in the delafossite lattice, serving as a p-type donor and increasing carrier concentration and photoinduced carrier lifetime. However, Wuttig *et al.* highlighted that the majority carrier can change from p-type to n-type near the Mg solubility limit ($x = 0.05$) in CuFeO_2 .¹⁴⁴ In addition to doping, other strategies to enhance CuFeO_2 properties, include a heterojunction with other materials, especially with CuO, performed using several of the above discussed methods.^{145–148}

To sum up, CuFeO_2 is a promising semiconductor for application as a photocathode for water splitting and the CO_2RR , with a lower band gap and higher stability in relation to its binary counterpart Cu_2O .^{147,148} However, the experimentally obtained PEC performance is lower than the theoretical estimated values (photovoltage of 0.8 V and photocurrent of $\sim 9 \text{ mA cm}^{-2}$),^{137,148,149} due to poor photoinduced electron-hole separation and collection. Thus, efforts for building adequate heterostructures using a combination of different synthesis methods can suppress surface and bulk recombination and improve the PEC performance of CuFeO_2 .¹⁴⁹



CuBi₂O₄. The mineral kusashiite CuBi₂O₄ (or Bi₂CuO₄) is a spinel-type material with tetragonal structure, consisting of planar CuO₄ complexes stacked along the *c*-axis.¹⁵⁰ As shown in Fig. 14(a) Bi atoms are arranged between the stacks, bonded to six oxygen atoms at three different bond distances.

CuBi₂O₄ behaves as a p-type semiconductor and has been considered a promising photocathode for PEC, especially water splitting, since 2007,^{14,151,152} due to the narrow optical bandgap (E_g ranging from 1.5 to 1.8 eV), VB edge located at a more positive potential than Cu₂O and CuFeO₂ (with a photocurrent onset potential near 1 V vs. RHE) and CB edge more negative than the thermodynamic reduction potential of H⁺/H₂ (0 V vs. RHE).¹³³ Recently, a CuBi₂O₄ photoelectrode was also investigated for the CO₂RR in 0.1 mol L⁻¹ KHCO₃ aqueous solution (pH = 6.8, CO₂ saturated), and produced CO at 0 V vs. Ag/AgCl. Also, ethanol and formaldehyde were produced using a photoelectrode consisting of a composite of CuBi₂O₄ with TiO₂ nanotubes in 0.1 M NaHCO₃ solution and -0.6 V vs. SCE.^{153,154}

CuBi₂O₄ can be synthesized from a combination of CuO and Bi₂O₃ in a 1:1 stoichiometry.¹⁵⁵ This can be visualized in a scheme in Fig. 14(b), which brings a diagram of different combinations of binary oxide precursors and the resulting complex multinary oxides. Considering A as CuO and B as Bi₂O₃, the yellow dot on the triangle edge middle would be the stoichiometric compound CuBi₂O₄. The addition of another C oxide, such as V₂O₅, could result in a quaternary oxide.

As for other complex oxides, conventional “dry” methods like SSR, are commonly employed for CuBi₂O₄ preparation. However, the reaction begins at temperatures over 600 °C, and CuBi₂O₄ melts over ~820 °C.^{152,156} Ball milling can be employed in combination to SSR, like in the work of Wei and co-workers, who prepared a p-n heterojunction photocatalyst of p-CuBi₂O₄/n-TiO₂,¹⁵⁷ but, according to Chen *et al.*, it must be carefully employed in the CuBi₂O₄ synthesis, as it can cause structural modifications.¹⁵⁸

Conventional “wet” methods have also been used for CuBi₂O₄ synthesis, although the occurrence of non-stoichiometry,¹⁵⁹ and

presence of CuO and Bi₂O₃ impurities is expected at lower temperatures (~200 °C).¹⁵⁶ The CuBi₂O₄ preparation by electro-deposition,¹⁵⁹ hydrothermal,^{160,161} and sol-gel methods,¹⁶² usually must be followed by heating treatments and the resulting electrodes give highly negative photoelectrochemical currents, like -1.5 mA cm⁻² at 0.45 V vs. Ag/AgCl for HER, and -0.1 mA cm⁻² at 0 V vs. Ag/AgCl for CO₂RR into CO.^{160,163–165}

Li *et al.*¹⁶⁶ reported the effect of the annealing conditions of CuBi₂O₄ directly synthesized on FTO *via* spin-coating of Cu and Bi nitrate solutions, with a hot plate (120 °C) and post-annealing over 450 °C in a furnace for 2 h. For comparison purposes, four different ramping rates were set (1 °C min⁻¹, 2 °C min⁻¹, 10 °C min⁻¹ and 20 °C min⁻¹). The CuBi₂O₄ electrode slowly heated at 2 °C min⁻¹ up to 450 °C achieved the highest photocurrent, 0.68 mA cm⁻² at 0.25 V_{RHE} in KOH/KCl electrolyte, pH 13.

Unconventional methods were also used for CuBi₂O₄ preparation; in 2017, Hossain *et al.* reported successful CuBi₂O₄ preparation *via* combustion solution synthesis; however, the samples also presented different quantities of residual CuO and Bi₂O₃.¹⁶⁷ The studies revealed that the electrode prepared with CuO/CuBi₂O₄ heterojunction, showed improved photocurrent in comparison with electrodes prepared with these oxides alone, which they attributed to a synergic effect of enhanced charge carrier separation in the nanocomposite. More recently, Gottesman *et al.* prepared high-crystalline and pure phase CuBi₂O₄ electrodes by the subsequential deposition of BiO₃ and CuO layers on FTO substrate with PLD at a substrate temperature at 500 °C, followed by a floating zone technique for crystal growth, and a rapid thermal process at 650 °C for 10 min.¹⁶⁸ In another study, a film of CuBi₂O₄ was directly deposited on FTO by PLD.¹⁵⁶ In both studies they observed higher photocurrents for samples with impurities, compared to the pure ones. The authors warned that conventional long furnace annealing, *e.g.* 500 °C for 72 h, can result in uncontrolled phase segregation and such impurities prevent the synthesis of pure phase CuBi₂O₄.¹⁵⁶ Thus, they advertised the importance of searching for pure phases to control PEC performance.

Lee and co-workers used PLD to prepare high-quality single crystal CuBi₂O₄ thin film using a NiO template layer grown on (001) SrTiO₃ single-crystal substrate.¹⁶⁹ Since PLD can be implicated in epitaxial relationships among the domains of each component, the substrate was carefully selected to guarantee the maximum compatibility and minimum tension of film/substrate crystal lattice parameters.¹⁷⁰ The resulting photocathode exhibits -0.4 mA cm⁻² at 0 V RHE under illumination in 0.1 mol L⁻¹ potassium phosphate solution; the addition of H₂O₂ as an electron scavenger intensified the photocurrent to -0.7 mA cm⁻².

The experimental performances reported for CuBi₂O₄ photoelectrodes are lower than its maximum theoretical photocurrent calculated as ~20 mA cm⁻² assuming 100% of absorption and conversion for photons with an energy above its E_g of 1.8 eV. According to Berglund *et al.*, the CuBi₂O₄ main limiting factor for PEC performance is the poor charge carrier transport



Fig. 14 (a) The CuBi₂O₄ crystal structure as viewed at an arbitrary angle. The Bi, Cu, and O atoms are represented by blue, orange, and red spheres, respectively. Reprinted (adapted) with permission from ref. 16 Copyright 2016 American Chemical Society. (b) Graphical visualization of ternary and quaternary oxides, for generic cases. Adapted from ref. 155 according to (CC BY, <https://creativecommons.org/licenses/by/4.0/>) ©The Author(s) 2018. Published by ECS.





Fig. 15 General timeline for the evolution of some reports in the literature of CuBi_2O_4 electrodes for PEC applications obtained by conventional “dry methods” (solid-state reaction, ball-milling) or “wet methods” (hydrothermal, electrodeposition) and by less conventional methods such as solution combustion synthesis and pulsed-laser deposition.

(primarily by holes), combined with its relatively weak optical absorption and instability in aqueous media.¹⁶

The strategies to circumvent these problems include, again, the nanostructuring, doping, surface modifications and also the use of protective layers.¹⁷¹ Moreover, suitable contact between CuBi_2O_4 and the conductive substrate must be assured. Furthermore, FTO is largely used as a substrate, but it should also be pointed out that there is a mismatch between the FTO work function and the CuBi_2O_4 Fermi level, which can create a Schottky barrier, prejudicing the hole transport.¹⁷² In this sense, it is also important to optimize the substrate and intermediate layers associated with the efforts for more adequate synthesis methods.

Fig. 15 shows a timeline for the evolution of CuBi_2O_4 synthesis methods, which includes the main discussed synthesis methods for the preparation of CuBi_2O_4 based photocathodes.

5. Conclusions

In summary, the generation of fuels based on PEC water splitting, CO_2 reduction or biomass valorisation using semiconductor electrodes are promising green technologies, but their real application depends on the efficiency and long-term stability of the materials used as photoelectrodes. Complex metal oxides with semiconductor properties can be the next generation materials for such PEC applications, due to the improved sunlight harvesting and enhanced stability in comparison to their binary counterparts. Moreover, the high number of possible combinations of metals (mainly the transition ones), can lead to novel (or little explored) complex oxides.

However, the performances of these innovative materials as photoelectrodes in PEC reactors are still much lower than the maximum theoretical photocurrent calculated from their E_g

values. Although complex oxides generally present interesting intrinsic properties, there are several kinetics and charge-transfer limitations, which must be circumvented to produce efficient photoelectrodes for PEC generation of fuels.

Comparison of PEC performances is not straightforward, since experimental conditions include numerous variables, such as electrode geometrical and electrochemical area, irradiation intensity, scavenger species, pH and electrolyte composition. However, photocurrent or faradaic efficiencies values have been presented here when these data were available.

The properties of complex oxides (as well as, for any material) can be improved by nanostructuring, doping, and/or with suitable heterojunctions. Since these strategies are synthesis-dependent, the choice of a reliable synthesis methodology is essential to develop multinary complex oxides which exhibit adequate characteristics for PEC applications.

The literature presents several methods to synthesize multinary oxides and the choice should consider advantages and disadvantages in terms of necessary facilities (precursors and equipment), and control of product characteristics (purity, crystallinity, morphology, thickness, and electrical contact with the substrate). While “dry” methods can easily produce crystalline complex oxides, “wet” methods are more favourable to control the morphology and grain size. Furthermore, a combination of different methods can be a good strategy to balance morphological and crystallinity aspects. However, an annealing step is usually necessary for the preparation of photoelectrodes with samples obtained from both routes. Moreover, the direct growth of complex oxide films on the conductive substrate by electrodeposition, CVD or PVD bring enhanced properties in terms of adherence and electrical contact, the required properties for photoelectrodes. Nevertheless, these methodologies are not trivial and cannot be largely applied for complex oxide synthesis.

Far from being an instructions guide, this work was an attempt to bring insights into the choice of a methodology to synthesize complex oxides for PEC applications, organized as “traditional” (widely used methods), and “unconventional” methods. This way, we hope to contribute to the development of more efficient materials for the next generation production of solar fuels, such as hydrogen from water splitting, C-based products from CO_2 or biomass valorisation and other reactions in the field of sustainable energy production.

Author contributions

All authors participated into the conceptualization of this work. CRediT: N. G. Macedo: methodology, writing – original draft (Introduction, “Wet” and Unconventional Methods, Photocathodes, Conclusion sections), writing – review & editing; J. C. A., L. C. S. & M. T. G.: writing – original draft (Fundamentals, “Wet” and Unconventional Methods); L. S.C. & L. C. S.: writing – original draft (“Dry” methods and Photoanodes); V. S. L.: writing – original draft (“Wet” and Photocathodes). C. Longo: supervision, resources, validation, writing-review &



editing. All authors approve the content of the manuscript and agree to be held accountable for the work.

Conflicts of interest

There are no conflicts to declare.

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